Supplemental material for "Using Activated Transport in Parallel Nanowires for Energy Harvesting and Hot Spot Cooling"

Riccardo Bosisio, Cosimo Gorini, Geneviève Fleury, and Jean-Louis Pichard Service de Physique de l'État Condensé, CNRS URA 2464, CEA Saclay, F-91191 Gif-sur-Yvette, France

## I. RESOLUTION OF THE RANDOM RESISTOR NETWORK PROBLEM

Hereafter, we summarize the numerical method used to solve the random-resistor network problem ${ }^{113}$. The threeterminal setup configuration is reminded in Fig. 1. with emphasis on the hopping transport mechanism taking place in the NWs. Starting from a set of states $i$ localized at positions $x_{i}$ inside the NWs, with energies $E_{i}$ and localization lengths $\xi_{i}$, we first evaluate the transition rates $\Gamma_{i \alpha}$ from the localized state $i$ to the reservoir $\alpha=L$ or $R$, and $\Gamma_{i j}$ from states $i$ to $j$ within the same wire (inter-wire hopping being neglected). They are given by the Fermi Golden rule as

$$
\begin{align*}
\Gamma_{i \alpha} & =\gamma_{i \alpha} f_{i}\left[1-f_{\alpha}\left(E_{i}\right)\right]  \tag{1}\\
\Gamma_{i j} & =\gamma_{i j} f_{i}\left(1-f_{j}\right)\left[N_{i j}+\theta\left(E_{i}-E_{j}\right)\right] \tag{2}
\end{align*}
$$

where $f_{i}$ is the occupation probability of state $i, f_{\alpha}(E)=\left[\exp \left(\left(E-\mu_{\alpha}\right) / k_{B} T_{\alpha}\right)+1\right]^{-1}$ is the Fermi distribution of reservoir $\alpha, N_{i j}=\left[\exp \left(\left|E_{j}-E_{i}\right| / k_{B} T\right)-1\right]^{-1}$ is the probability of having a phonon with energy $\left|E_{j}-E_{i}\right|$ assisting the hop, and $\theta$ is the Heaviside function. In Eq. (1), $\gamma_{i \alpha}=\gamma_{e} \exp \left(-2 x_{i \alpha} / \xi_{i}\right), x_{i \alpha}$ denoting the distance of state $i$ from reservoir $\alpha$, and $\gamma_{e}$ being a constant quantifying the coupling from the localized states in the NW to the extended states in the reservoirs. Usually, $\xi_{i} \approx \xi(\mu)$ is assumed and the rate $\gamma_{i j}$ in Eq. (2) is simply given by $\gamma_{i j}=\gamma_{e p} \exp \left(-2 x_{i j} / \xi(\mu)\right)$, with $x_{i j}=\left|x_{i}-x_{j}\right|$ and $\gamma_{e p}$ measuring the electron-phonon coupling. Since this approximation does not hold in the vicinity of the impurity band edges, where the localization lengths vary strongly with the energy, we use a generalized expression for $\gamma_{i j}$ that accounts for the different localization lengths $\xi_{i} \neq \xi_{j}$ (see Ref. ${ }^{[4]}$ ).

By using Eqs. (1)- (22 and imposing charge conservation at each network node $i$, we deduce the $N f_{i}$ 's of the $M$ independent NWs. The charge and heat currents flowing from reservoir $\alpha$ to the system can then be calculated as $I_{\alpha}^{e}=e \sum_{i} I_{\alpha i}$ and $I_{\alpha}^{Q}=\sum_{i} I_{\alpha i}\left(E_{i}-\mu_{\alpha}\right)$, where $I_{\alpha i}=\Gamma_{\alpha i}-\Gamma_{i \alpha}$ and $e$ is the electron charge. In principle, the heat current $I_{P}^{Q}=(1 / 2) \sum_{i} I_{i}^{Q}$ coming from the phonon bath can be calculated as well but in the letter, we only investigated the behavior of the local heat currents $I_{i}^{Q}=\sum_{j}\left(E_{j}-E_{i}\right) I_{i j}^{N}$ with $I_{i j}^{N}=\Gamma_{i j}-\Gamma_{j i}$. Without loss of generality, we choose the right terminal $R$ as the reference, i.e. we set $\mu_{R}=\mu, T_{R}=T$ and we impose on the left side $\mu_{L}=\mu+\delta \mu, T_{L}=T+\delta T$. Using the Onsager formalism, we relate the particle $\left(I_{L}^{e}\right)$ and heat $\left(I_{L}^{Q}\right)$ currents computed in linear response to the small imposed bias $\delta \mu$ and $\delta T^{5}$. This allow us to deduce the thermoelectric coefficients $G$, $K^{e}$ and $S$.


FIG. 1. Phonon-assisted hopping transport through the localized states (dots) of a disordered NW connected to two electrodes $L$ and $R$, and to a phonon bath. The electronic reservoirs $L$ and $R$ are thermalized at temperatures $T_{L[R]}$ and held at electrochemical potentials $\mu_{L[R]}$ (their Fermi functions are sketched by the black curves at both sides). A metallic gate (shaded grey plate drawn on top) allows to shift the NW impurity band (blue central region). Here, the gate potential $V_{g}$ is adjusted such that electrons tunnel in and out of the electronic reservoirs near the lower edge of the impurity band. Therefore, electrons tend to absorb phonons at the entrance in order to reach available states of higher energies, and to emit phonons on the way out. The two wavy arrows indicate the local heat flows between the NW electrons and the phonon bath. They give rise to a pair of cold (blue) and hot (red) spots in the substrate beneath the NW (in the deposited setup configuration).


FIG. 2. (Color online) Convergence of $G / M$ (left, in units of $e^{2} / \hbar$ ) and $S$ (right) with the number $M$ of parallel NWs. Symbols correspond to $V_{g}=1.9 t(\circ), 2.1 t(\square)$ and $2.3 t(\diamond)$ at $k_{B} T=0.1 t$, and $V_{g}=1.9 t$ at $k_{B} T=0.5 t(\triangle)$. The horizontal lines indicate the corresponding mean values (dashed lines) and typical values (full lines) of $\ln G$ and $S$ of a single wire ( $M=1$ ). Parameters: $W=t, \gamma_{e}=\gamma_{e p}=t / \hbar$ and $L=450 a$.

## II. SCALING OF THE THERMOELECTRIC COEFFICIENTS WITH THE NUMBER OF NANOWIRES

The typical conductance $G_{0}$ and thermopower $S_{0}$ of a single NW were studied in Ref. ${ }^{[4}$. They are defined as the median of the distribution of $\ln G$ and $S$, obtained when considering a large statistical ensemble of disorder configurations. In Fig. 2 we show that, if the system is made of a sufficiently large number $M>M^{*}$ of parallel NWs, the overall electrical conductance scales as the number of wires times the typical value ( $G \approx M G_{0}$ ), while the thermopower averages out to the typical value of a single wire ( $S \approx S_{0}$ ). For completeness the mean values are also shown and seen to be a less accurate estimate. As expected, convergence is faster at higher temperatures. Note that identical results have been obtained for the electronic thermal conductance $K^{e} \approx M K_{0}^{e}$ (not shown).

## III. SIZE EFFECTS

We have investigated the effects on the various transport coefficients $G, K^{e}$ and $S$, the power factor $\mathcal{Q}$, and the electrical figure of merit $Z_{e} T$, of varying the length $L$ of the NWs. The results are shown in Fig. 3 , for three values of the temperatures $k_{B} T=0.1 t, 0.5 t$ and $1.0 t$, and for two configurations corresponding to bulk $\left(V_{g}=t\right)$ and edge transport $\left(V_{g}=2.5 t\right)$. We observe that they are essentially always size-independent, for $\mu$ inside the impurity band and also around its edge. The only exception is the electrical conductance at low temperatures and in the case of edge transport: this causes the electrical figure of merit $Z_{e} T$ to decrease in this regime (。in Fig. 3(d)) roughly as $1 / L$. However, being interested in the regime of temperatures where the power factor is largest ( $k_{B} T \simeq 0.5 t$ ), we can conclude that the size effects on the results shown in the letter are completely negligible. Also, we note that the small fluctuations observed especially at the smallest sizes are a consequence of having taken a finite number of parallel NWs $(M=150)$ : they would vanish in the limit $\mathrm{M} \rightarrow \infty$ due to self-averaging.

## IV. ON THE DEPENDENCE ON THE COUPLINGS $\gamma_{e}$ AND $\gamma_{e p}$

In this section, we investigate how the transport coefficients $G, K^{e}$ and $S$, the power factor $\mathcal{Q}=S^{2} G$ and the electrical figure of merit $Z_{e} T=S^{2} G T / K^{e}$ depend upon varying the couplings $\gamma_{e}$ and $\gamma_{e p}$ of the localized states with the electrodes and the phonon bath, respectively. We introduce the notation $\alpha \equiv \gamma_{e p} / \gamma_{e}$. We first notice that if $\alpha$ is kept fixed, the electrical conductance $G$ and the electronic thermal conductance $K^{e}$ are strictly proportional to $\gamma_{e}$, while the thermopower $S$ is independent of it. This behavior is a direct consequence of the formulation of the random resistor network problem and can be seen at the stage of writing the equations (see Ref. ${ }^{[4]}$ ), before solving them numerically. Therefore, for any fixed $\alpha, \mathcal{Q} / \gamma_{e}$ and $Z_{e} T$ are necessarily independent of the choice of $\gamma_{e}$. We thus find that $G / \gamma_{e}, K^{e} / \gamma_{e}, S, \mathcal{Q} / \gamma_{e}$ and $Z_{e} T$ are functions of the single parameter $\alpha$, and not of the couple of parameters $\gamma_{e}$ and $\gamma_{e p}$ separately. Those functions are plotted in Fig. 4 (a)-(c) for two different temperatures. The conductances, the power factor and the figure of merit increase with $\alpha$ (as long as lack of phonons is a limiting factor to transport


FIG. 3. (Color online) Behavior of the transport coefficients as function of the NWs size $L$ (in units of the spacing $a$ ). Panels from left to right show (a) the rescaled electronic contribution to the thermal conductance $K^{e}$ (in units of $k_{B} t / \hbar$ ), (b) the thermopower $S$ (in units of $k_{B} / e$ )), (c) the rescaled power factor $\mathcal{Q}$ (in units of $k_{B}^{2} / \hbar$ ) and (d) the electrical figure of merit $Z_{e} T$. In all the four panels, different symbols correspond to $k_{B} T=0.1 t$ (circles), $k_{B} T=0.5 t$ (squares) and $k_{B} T=t$ (rhombus), while different colors refer to the case of bulk transport ( $V_{g}=t$, black) and edge transport ( $V_{g}=2.5 t$, red). Dotted lines are guides to the eye. Other parameters are fixed to $W=t$ and $\gamma_{e}=\gamma_{e p}=t / \hbar$.


FIG. 4. (Color online) Dependency of $G, K^{e}, S, \mathcal{Q}$ and $Z_{e} T$ on the ratio $\gamma_{e p} / \gamma_{e}$. (a) Electrical ( $G / M$, black full symbols) and thermal ( $K^{e} / M$, red empty symbols) conductances, in units of $e^{2} / \hbar$ and $k_{B} t / \hbar$ respectively. (b) Thermopower in units of $k_{B} / e$. (c) $\mathcal{Q} / M$ in units of $k_{B}^{2} / \hbar$ (black full symbols) and $Z_{e} T$ (red empty symbols). In all panels, different symbols correspond to $k_{B} T=0.2 t$ (circles) and $k_{B} T=0.5 t$ (triangles), while dotted lines are guides to the eye. Data have been plotted for a given set of $M=150$ parallel NWs of length $L=450 a$, with $\gamma_{e}=t / \hbar, W=t$ and $V_{g}=2.4 t$. Note that when $\gamma_{e p} \gtrsim \gamma_{e}$ all these coefficients are nearly constant.
through the NWs), while the thermopower decreases. All of them tend to saturate for $\alpha \gtrsim 1$. This shows us, inter alia, that $\mathcal{Q} / \gamma_{e}$ and $Z_{e} T$ are essentially independent of $\gamma_{e}$ and $\gamma_{e p}$ if $\gamma_{e p} \gtrsim \gamma_{e}$ and that they only deviate slowly from this limit if $\gamma_{e p}<\gamma_{e}$. Such a robustness of $\mathcal{Q} / \gamma_{e}$ and $Z_{e} T$ to variations of $\gamma_{e}$ and $\gamma_{e p}$ reinforces the impact of the results shown in the letter.

## V. HOT SPOTS

In this section, we provide more details concerning the effect of generating hot and cold spots using a semiconductor NWs-based device in the field effect transistor configuration. As stated in the letter, each NW exchanges locally a certain amount of heat with the substrate. The global effect of substrate heating/cooling is visible after summing the heat currents inside areas of size $\approx \Lambda_{p h}$, the (inelastic) phonon mean free path, which is a measure of the thermalization length in the substrate.

Before detailing this, we illustrate in Fig. 5 an example of the map of the raw heat currents $I_{i}^{Q}$ locally exchanged with the substrate. The horizontal coordinate is the position along the NW (in units of $a$, the average distance between localized states), while the vertical one labels each NW. In this case, we see that the $I_{i}^{Q}$, sfluctuate between positive and negative values at random positions of the substrate, and thus no net effect emerges.


FIG. 5. Map of the local heat currents $I_{i}^{Q}$ exchanged between the NWs and the substrate at each NWs site $i=(x, y)$, for $k_{B} T=0.05 t$ and $V_{g}=2.25 t$. The presence of hot and cold spots is hidden by the fluctuations. They emerge when the raw $I_{i}^{Q}$ data are summed up within areas of size $\Lambda_{p h} \times \Lambda_{p h}$. Parameters: $M=150, L=450 a, W=t, \gamma_{e}=\gamma_{e p}=t / \hbar$ and $\delta \mu=10^{-5} t$.

The formation of the hot and cold spots is a process which becomes visible only upon summing in a single term $\mathcal{I}_{x, y}^{Q}$ all the contributions $I_{i}^{Q}$ coming from states $i$ located in a small area around the point of coordinates $(x, y)$. Physically, the typical size of those areas corresponds to the thermalization length of the substrate. It is given by the inelastic phonon mean free path $\Lambda_{p h}$. This mean free path may be different for different phonon wavelengths, and while it does not change much around room temperatures, it can vary significantly at lower (still not vanishing) temperatures. It is possible to relate $\Lambda_{p h}$ to the dominant phonon wave length ${ }^{6}$ as $\Lambda_{p h}=300 \lambda_{p h}^{\text {dom }}$, where the coefficient 300 is for $\mathrm{SiO}_{2}$ and may be different for other materials. This allows the calculation of the mean free path, once $\lambda_{p h}^{d o m}$ is known. According to Refs. ${ }^{[78}$, the latter can be estimated as

$$
\begin{equation*}
\lambda_{p h}^{d o m} \simeq \frac{h v_{s}}{4.25 k_{B} T} \tag{3}
\end{equation*}
$$

where $h$ is the Planck constant. Taking $v_{s}=5300 \mathrm{~m} / \mathrm{s}$ the sound velocity in $\mathrm{SiO}_{2}^{[8]}$, we can easily deduce $\lambda_{p h}^{d o m} \simeq 0.2 \mathrm{~nm}$ from which $\Lambda_{p h} \simeq 60 \mathrm{~nm}$ at room temperature $T=300 \mathrm{~K}$. Values of $\Lambda_{p h}$ at other temperatures follow immediately from the temperature dependence in Eq. (3). We shall stress that the real values of $\Lambda_{p h}$ may differ from our prediction by a small numerical factor, which however is not important within our qualitative approach. To convert these lengths in the units used in the letter, we assume the average distance between localized states $a \approx 3.2 \mathrm{~nm}$ in highly doped silicon NWs, which together with $t / k_{B} \approx 150 K$ allows us to estimate for example $\Lambda_{p h} \approx 75 a$ at $T=0.5 t / k_{B}=75 \mathrm{~K}$.

In Fig. 6, we consider a set of $M=150$ parallel NWs of length $L=1500 a \approx 4.8 \mu \mathrm{~m}$ with interspacing $15 a \approx 50 \mathrm{~nm}$ among them. This choice of interspacing value corresponds to an array made of NWs of 10 nm diameter with $20 \%$ packing density. We show in the figure how $\mathcal{I}_{x, y}^{Q}$ vary spatially with the positions $x, y$ in the substrate below the two-dimensional array of parallel NWs. Data are given for two different values of the temperature (top/bottom) and of the gate voltage (left/right). The top panels are the same as those presented in Fig. 2 of the letter. In this case, $T=0.25 t / k_{B}=37.5 \mathrm{~K}$ and $\Lambda_{p h} \approx 150 a$. Data show us that the hot and cold spots are visible only in presence of a large gate voltage, when the distribution of the energy states in the NWs is strongly asymmetric with respect to $\mu$. The bottom panels of Fig. 6 show how the heat maps are modified when the temperature is doubled to $T=0.5 t / k_{B} \approx 75 \mathrm{~K}$. According to the prescription briefly discussed above, $\Lambda_{p h}=75 a$ in this case. The fact that the surface inside which the heat currents are summed up is now smaller is compensated by a smoothing of the $I_{i}^{Q}$,s fluctuations at larger temperature. This makes the hot and cold spots still clearly visible and well-defined in panel (d).

[^0]

FIG. 6. Map of the local heat exchanges $\mathcal{I}_{x, y}^{Q}$ between the NWs and the phonon bath (substrate), in units of $t^{2} / \hbar$. Various panels correspond to different gate voltages and temperatures: $V_{g}=0.0$ in (a) and (c), $V_{g}=2.25 t$ in (b) and (d), $k_{B} T=0.25 t$ in (a) and (b), $k_{B} T=0.5 t$ in (c) and (d). The heat currents have been summed inside areas of size $\Lambda_{p h}=75 a$ for $k_{B} T=0.5 t$ and $\Lambda_{p h}=150 a$ for $k_{B} T=0.25 t$, as explained in the text. Note that the formation of hot and cold spots at the boundaries of the NWs is clearly visible for both temperatures when $V_{g}$ is tuned in order to probe their band edges ((b) and (d)), while no net effect is evident in absence of any gate voltage ((a) and (c)). In all panels, data have been plotted for $M=150$ NWs of length $L=1500 a$ with interspacing $15 a$. Other parameters are $W=t, \gamma_{e}=\gamma_{e p}=t / \hbar$ and $\delta \mu=10^{-3} t$.

[^1]
[^0]:    ${ }^{1}$ A. Miller and E. Abrahams, Phys. Rev. 120, 745 (1960).
    ${ }^{2}$ V. Ambegaokar, B. I. Halperin, and J. S. Langer, Phys. Rev. B 4, 2612 (1971).

[^1]:    ${ }^{3}$ J.-H. Jiang, O. Entin-Wohlman, and Y. Imry, Phys. Rev. B 87, 205420 (2013).
    ${ }_{5}^{4}$ R. Bosisio, C. Gorini, G. Fleury, and J.-L. Pichard, arXiv:1403.7475(2014).
    ${ }^{5}$ H. Callen, Thermodynamics and an Introduction to Thermostatics (John Wiley and Sons, New York, 1985).
    ${ }_{7}^{6}$ R. O. Pohl, X. Liu, and E. Thompson, Rev. Mod. Phys. 74, 991 (2002).
    ${ }^{7}$ T. Klitsner and R. O. Pohl, Phys. Rev. B 36, 6551 (1987).
    ${ }^{8}$ J. M. Ziman, Electrons and Phonons: The Theory of Transport Phenomena in Solids (Clarendon Press, 1996).

